Juho Taipale

DEVELOPMENT OF RELIABILITY TESTING AUTOMATION FOR MICROWAVE RADIOS

Thesis submitted for examination for the degree of Master of Science in Technology

Espoo 16.09.2009

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In my master’s thesis I have studied how automation makes reliability testing of a microwave radio outdoor unit more efficient. Two new test cases, that are done manually so far, will be added to an existing automation software. The goal is to speed up reliability testing and decrease resources needed for it.

Microwave radios used in radio links are divided into two physical parts. One of them is indoor unit and the other is outdoor unit. The latter has to endure in outdoor conditions.

Performance of the microwave radio outdoor unit can be investigated with several test cases. The scope of these test cases is to get detailed information about the radio. This helps locating malfunctioning unit or component in the hardware. On one test run these test cases are repeated several times with different outdoor unit transmission settings and quite a lot of manual work is needed. Including new test cases in the existing automation software reduces time spent on testing and the amount of work needed for it. Also, benefits of automation are good reproducibility of measurements and the lack of human errors.
Tekijä: Juho Taipale

Työn nimi: Mikroaalteradioiden luotettavuustestauksessa käytettävän automaation kehittäminen


Tiedekunta: Elektroniikan, tietoliikenteen ja automaation tiedekunta

Professuuri: Radiotekniikka   Koodi: S-26

Valvoja: Prof. Antti Räisänen

Ohjaaja: DI Ville Hämäläinen

Diplomityössäni tutkin, miten mikroaalteradioiden ulkoyksikön luotettavuustestaus tehostuu automatisoinnin avulla. Olemassa olevaan automaatioon on tarkoitus liittää kaksi uutta mittauta, jolloin niitä ei tarvitse erikseen tehdä käsin. Tarkoituksena on nopeuttaa testausta ja vähentää siinä tarvittavia resursseja.


Avainsanat: Luotettavuustestaus, automaatio
Preface

This master’s thesis was done for Nokia Siemens Networks during 2008 and 2009. First of all I am very grateful to MSc Ville Hämäläinen whose effort made it possible for me to do this master’s thesis. Also I would like to thank him for his inspiring guidance and for his insights on the topic of this thesis. Secondly, I would like to thank Professor Antti Räisänen at Helsinki University of Technology for his valuable feedback.

The work started with getting familiar with the software development environment of the test automation. I am very grateful to Antero Tyrväinen who was of great help with his expertise in the automation software. His guidance was crucial especially in the beginning of the project. Thanks to Petteri Aleksejev for teaching me how reliability testing is done in practice. I want to thank all the people at NSN who have contributed to this work. Also I want to thank my family and friends for their support.

Otaniemi, 16.09.2009

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Symbols, operators and abbreviations

Symbols

\[ E_a \] activation energy
\[ F \] cumulative failure probability
\[ k \] Boltzmann’s constant

Operators

\( \alpha' \) first derivative of \( \alpha \)
<table>
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<th>Abbreviation</th>
<th>Definition</th>
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<tr>
<td>ADE</td>
<td>application development environment</td>
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<td>AF</td>
<td>acceleration factor</td>
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<tr>
<td>AGC</td>
<td>automatic gain control</td>
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<td>ALT</td>
<td>accelerated life testing</td>
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<td>API</td>
<td>application programming interface</td>
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<td>ASD</td>
<td>acceleration spectral density</td>
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<td>ASIC</td>
<td>application-specific integrated circuit</td>
</tr>
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<td>AST</td>
<td>accelerated stress test</td>
</tr>
<tr>
<td>C</td>
<td>programming language</td>
</tr>
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<td>CERT</td>
<td>combined environmental reliability testing</td>
</tr>
<tr>
<td>CVI</td>
<td>C for virtual instrumentation</td>
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<td>DLL</td>
<td>dynamic link library</td>
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<td>DQPSK</td>
<td>differential quadrature phase shift keying</td>
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<td>EM</td>
<td>electromigration</td>
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<td>EMD</td>
<td>early mode dielectric breakdown</td>
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<td>ESD</td>
<td>electrostatic discharge</td>
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<td>FDD</td>
<td>frequency division duplex</td>
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<td>FEC</td>
<td>forward error correction</td>
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<td>FMECA</td>
<td>failure modes, effects and criticality analysis</td>
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<td>GPIB</td>
<td>general purpose interface bus</td>
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<td>GPIO</td>
<td>general purpose I/O</td>
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<td>HALT</td>
<td>highly accelerated life testing</td>
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<td>HAST</td>
<td>highly accelerated stress testing</td>
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<td>IC</td>
<td>integrated circuit</td>
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<td>IF</td>
<td>intermediate frequency</td>
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<tr>
<td>IFU</td>
<td>intermediate frequency unit</td>
</tr>
<tr>
<td>KSI</td>
<td>thousands of psi</td>
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<td>LAN</td>
<td>local area network</td>
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<td>LNA</td>
<td>low noise amplifier</td>
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<td>LO</td>
<td>local oscillator</td>
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<tr>
<td>MOSFET</td>
<td>metal oxide semiconductor field effect transistor</td>
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<tr>
<td>MTBF</td>
<td>mean time between failures</td>
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<td>MTTF</td>
<td>mean time to failure</td>
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<tr>
<td>MWU</td>
<td>microwave unit</td>
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<td>PCB</td>
<td>printed circuit board</td>
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<td>PSU</td>
<td>power supply unit</td>
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<td>QFD</td>
<td>quality function deployment</td>
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<td>RF</td>
<td>radio frequency</td>
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<td>REF</td>
<td>reference unit</td>
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<td>RX</td>
<td>receive</td>
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<td>TCM</td>
<td>trellis coded modulation</td>
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<td>TDD</td>
<td>time division duplex</td>
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<td>TDDDB</td>
<td>time dependent dielectric breakdown</td>
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<tr>
<td>TX</td>
<td>transmit</td>
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<td>UUT</td>
<td>unit under test</td>
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<tr>
<td>VEE</td>
<td>visual engineering environment</td>
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<tr>
<td>VMEbus</td>
<td>VersaModular Eurocard bus</td>
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<tr>
<td>VXI</td>
<td>VMEbus extensions for instrumentation</td>
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1 Introduction

Reliability testing is implemented in different stages of microwave radio life cycle – from design to on-going testing at the stage of production. The most important stage of doing it is the design qualification because the benefits are realized over the whole life of the product. Production sampling or stress screening is performed regularly in order to monitor the production process for manufacturing and component quality variations.

In reliability testing of microwave radio outdoor unit some stress, like temperature cycling or vibration, is used to precipitate degradation. This may result in failures during testing or decreased performance after the stress test. Performance of the unit under test can be measured with several tests.

Reliability testing process consists of calibration of the test system, carrying out test cases before and after the stress cycle, stress cycle and overview of the results. Comparing test case results that were obtained before and after the stress cycle with one another gives information about the deterioration of the unit under test during stress cycle. These test cases are done with different transmission settings of the microwave radio and in several temperatures. Manually changing settings, taking measurements, making graphs, checking results and storing results is quite arduous and time consuming. Therefore automation software should handle the test case execution. The program can also be used for performance demonstration for customers or for checking only that the tested unit meets regulatory standards.

The implementation of two new test cases to an existing reliability testing automation software was done as a thesis work in Nokia Siemens Networks.

Theory part of this thesis begins with a definition of the reliability in 2. Chapter. Chapter 3 introduces a concept where the strength of the equipment and the stress level are presented as probability density functions. This illustrates how the probability of failure is affected by the strength of the equipment and the stress level when random errors are not taken into account. Chapter 4 shows how the damage inflicted by stress degrades the equipment over time. Chapter 5 presents most common failure mechanisms and also gives examples of some errors in design and manufacture that have been known to cause early failures. Chapter 6 gives practical view to accelerated stress testing and presents methods for doing it. Chapter 7 introduces the test subject, FlexiHopper Plus outdoor unit, for which the reliability testing automation is designed for. The test cases that will be performed to the outdoor unit are presented in Chapter 8. Chapter 9 defines the problem and presents the work assignment. Chapter 10 shows the software architecture of the test automation and gives short introductions to the main programming tools VEE Pro and Teststand. Chapter 11 tells about the implementation of the software. Results are presented in Chapter 12 and conclusion is in Chapter 13.
2 Reliability

There are several ways to define reliability. A commonly used definition and the definition used in this thesis is:

"Reliability is the probability that an item operating under stated conditions will survive for a stated period of time."

The above definition has its roots in military handbook MIL-STD-721C [1]. The above definition is valid for non-repairable hardware items. The "item" may be a component, a sub-system or a system. If the item is software instead of hardware, the definition will be somewhat different [2].

2.1 Reliability block diagram

A system can be divided into sub-systems. Each sub-system has reliability that is not dependable of reliabilities of other sub-systems. In Figure 1 a) sub-systems are in series and in Figure 1 b) they are parallel to each other. The former system works only if both blocks are working and the latter system works if at least one of the blocks is working.

Figure 1: Reliability block diagram of a: a) system in series, b) parallel system

Reliability of these systems in Figure 1 can be counted if the reliabilities $R_1$ and $R_2$ of the units are known. For the series system in Figure 1 a) reliability is

$$R_s = R_1 R_2 \quad (1)$$

For parallel system in Figure 1 b) reliability is

$$R_p = 1 - (1 - R_1)(1 - R_2) \quad (2)$$
3 Strength versus stress load

Strength of a product is defined as the maximum stress load the product can withstand without a failure. Every product is different from each other due to component variation and limited reproducibility in manufacturing and so the strengths of products vary. Strength can therefore be presented as probability density distribution. [3, pp. 115]

The bigger the variation in strength is the more there are weak units. Varying component values and inaccuracy in manufacturing don’t normally enhance the durability of the products. [3, pp. 116]

'Stress' may refer to a mechanical stress due to temperature cycling, vibration, humidity or so on. It can be presented as a probability density distribution, because the products are under environmental conditions that are different from each other. [3, pp. 114]
Stress and strength distributions can be placed in the same graph. If the distributions don’t overlap each other, as seen in Figure 4, there will be no failures. Practically this means that every unit can surely withstand the current stress, because lowest strength level is higher than highest applied stress level. Random failures are not taken into account.

Over time, the strength of units decreases due to degradation, but the stress load distribution remains still unchanged. When these two distributions overlap, failures among the weakest units become probable. [3, pp. 115]

The pattern of failures that dominate in the field can be approximated in three ways according to the time of failure in the life span of a product.
1. There are early life failures that are due to defects in products. These failures are also known as ‘infant mortalities’.

2. The failures caused by defects decrease rapidly and the dominant failure mechanisms are externally induced failures, which have rather constant rate of occurrence all the time. At this point the failure rate is at its minimum.

3. When the strength of the products deteriorates due to stress induced fatigue, wear out takes place as the dominant failure mechanism. [5, pp. 3-4]

When all of these failure types are superimposed, a curve called the bathtub curve occurs. One of a kind is shown in Figure 6.

Figure 6: Bathtub curve.
4 Fatigue damage

Many failures in electronic equipment are mechanical in nature. One common failure mode is mechanical fatigue damage due to cyclic stresses caused by temperature, temperature cycling, vibration or some combination of them. [5, pp. 15-16]

Miner’s criterion is one of the least complex ways to model fatigue damage. This criterion states that the fatigue damage is cumulative, non-reversible and accumulates on a simple linear basis. The damage accumulated under each stress condition taken as a percentage of the total life expended can be summed up over all stress conditions. When the sum reaches unity, the end of fatigue life has arrived and failure occurs. Fatigue damage based on Miner’s criterion is: [6]

\[ D \approx NS^\beta, \]

where \( D \) is the Miner’s criterion fatigue damage accumulation, \( N \) is the number of cycles of stress, \( S \) is the mechanical stress in force per unit area and \( \beta \) is a material property.

Stress versus number of cycles to fail diagram by Steinberg [7] is presented in Figure 7.

![Figure 7: S-N diagram for 7075 aluminium [7].](image)

The graph is derived from tensile fatigue tests on specimens and illustrates that the relationship between the number of cycles to fail and tensile stress is exponential in nature and verifies that an equation as (3) exists. Material property \( (\beta) \) is derived from the slope of the curve and, for most materials, ranges between 8 and 12 for most materials in high cycle fatigue. S-N diagrams for other materials are similar in nature. [5, pp. 133]

For a demonstration of the diagram in Figure 7, which is for 7075-T6 aluminium, following tensile stress levels and corresponding number of cycles to fail are chosen:

1. At 40 KSI (thousands of psi) it takes 2 million cycles to fail
2. At 80 KSI it takes 2000 cycles to fail.
Increasing stress by a factor of 2 causes decrease in life by factor of 1000. This acceleration factor is very typical for mechanically induced fatigue and for many other failure modes as well. Part that has imperfections may have higher stress concentrations. Even small imperfection may lead to stress two or even three times as high as in a part without imperfection - in other words the stress concentration factor is two or three. For example, if the stress concentration factor is 2 and $\beta$ is 10, then the acceleration factor is about 1 million. [5, pp. 133]

The fatigue damage that cycles do is non-reversible and cumulative. Cycles of high stress during testing do as much fatigue damage as cycles of low stress in the field environment and this is what makes it possible to utilize accelerated stress testing for finding weaknesses in products and validating the reliability of a product in a fraction of expected life time of the product.

Using S-N curves as a tool for design against fatigue have obvious limitations. One severe limitation is that they do not distinguish between crack initiation and crack propagation. Particularly in the low-stress regions, a large fraction of a component’s life may be spent in crack propagation, thus allowing for crack tolerance over a large portion of the life. Engineering structures often contain flaws or crack-like defects which may altogether eliminate the crack-initiation step. Therefore a method that quantitatively describes crack growth as a function of the stress loads is of great value in design and in assessing the remaining lives of components. [8]
5 Failure mechanisms

5.1 Solder joint fatigue

During temperature cycling conditions, solder joints experience a complex stress and strain history. The stress and strain in the solder joint result from the mismatch of the coefficient of thermal expansion between the package and the substrates, and the total CTE mismatch between the solder and copper pads/leads. This mismatch, which is sketched in figure 8, will cause the fatigue failure of solder joints. [9, pp. 152]

Figure 8: Thermal effects in soldered joint connecting a chip carrier (CC) to a substrate (PWB). (a) Initially unstressed solder joint. (b) Solder joint is heated to \( T_{\text{max}} \), expanding PWB relative to CC. (c) Solder joint is cooled to \( T_{\text{min}} \), contracting PWB relative to CC.

The process of this failure mechanism is:

1. crack nucleation
2. crack growth
3. ultimate ductile failure.
The thermal fatigue of solder joints depends on a number of parameters related to materials, pad surface finishes, geometry and the manufacturing processes. Besides thermal-mechanical fatigue failures, the impact of solder joint failures is a major issue for the electronics industry because of the ever increasing popularity of portable electronics and the transition to lead-free solders. [9, pp. 152]

5.2 Time dependent dielectric breakdown

One of the most important failure mechanisms in semiconductor technology is time dependent dielectric breakdown (TDDB). TDDB refers to the wear out process in gate oxide of the transistors. Other main contributors to semiconductor device wear out are electromigration and hot carrier effect. The exact physical mechanisms leading to TDDB are still unknown [10] [11].

Currently, the accepted model for oxide breakdown is the percolation model, in which breakdown occurs when a conduction path is formed by randomly distributed defects generated during electrical stress. It is believed that when this conduction path is formed, soft breakdown happens. When a sudden increase in conductance occurs, as well as a power dissipation rate higher than a specific threshold, hard breakdown occurs. The whole process is very complicated, but can be explained by the physics of breakdown [12].

In general, the electric field in MOSFET causes dielectric degradation and conductive path formation in dielectric material, which somehow connects the anode and cathode. Then, the continuous stress of the electric field on the gate oxide leads to thermal runaway through the breakdown path (soft breakdown) or energy dissipation (hard breakdown). The oxide breakdown leads to an increase in the gate current. The whole process can be modeled physically and mathematically. The models provide the lifetime function of the device. [9, pp. 89]

Further studies show that, while there is neither microscopic information about the breakdown defect and the interaction with stress voltage and temperature, nor a complete explanation of temperature dependence of dielectric breakdown of ultra-thin dielectric layers, there are empirical relations between voltage and temperature stresses. [9, pp. 92]

5.2.1 Early models for dielectric breakdown

During electrical stress, the time to dielectric breakdown depends on the electric stress parameters such as the electric field, temperature and the total area of the dielectric film. From the 1970s until 2000, several models were suggested for the time-to-breakdown in dielectric layers.

The intrinsic failure, which occurs in defect-free oxide, is modeled in four forms:

- Bandgap ionization occurs in thick oxides, when the electron energy reaches the oxide bandgap and causes electron-hole pairs.
- Anode hole injection (the 1/E model) occurs when electrons injected from the cathode gate get enough energy to ionize the atoms and create hot holes. Some of the holes tunnel back to the cathode and either create traps in the oxide, or increase the cathode field, leading to sudden oxide breakdown. The time to breakdown ($t_{BD}$) has a reciprocal electric field dependence from the Fowler-Nordheim electron tunneling current:

$$t_{BD} = t_0 \exp \left( \frac{G}{E_{OX}} \right) \exp \left( \frac{E_a}{kT} \right),$$

where $E_{OX}$ is the electric field across the oxide and $G$ and $t_0$ are constants.

- The thermo-chemical (E) model relates defect generation to the electrical field. The applied field interacts with the dipoles and causes oxygen vacancies and, hence, oxide breakdown. The lifetime function has the following form:

$$t_{BD} = t_0 \exp (\gamma E_{OX}) \exp \left( \frac{E_a}{kT} \right),$$

where $\gamma$ and $t_0$ are constants.

- Anode-hydrogen release happens when electrons at the anode release hydrogen, which subsequently diffuses through the oxide and generates electron traps. [9, pp. 90]

For thick dielectrics, the dielectric field is an important parameter controlling the breakdown process, while temperature dependence of dielectric breakdown is another key point. The $E$ and 1/E models can only fit part of the electric field, as shown in Figure 11. There are some articles in the literature that tried to unify both models [13] [14] [15]. However, both of those models are not applicable to the ultra-thin oxide layers. For ultra-thin oxide layers (between 2 to 5 nm), other models are used.

### 5.2.2 Models for Ultra-Thin Dielectric Breakdown

The dielectric thickness of modern semiconductor devices has been steadily decreasing. The time dependent breakdown of thin dielectric gets the following form [9, pp. 91]:

$$t_{BD} = A \left( \frac{1}{WL} \right)^{1/\beta} F^{1/\beta V_{GateToSource}} \exp \left( \frac{a(V)}{T} + \frac{b(V)}{T^2} \right),$$

where $W$ and $L$ are the width and length of the channel respectively, $F$ is cumulative failure probability, $A$ is acceleration factor, and $\beta$, $a$, $b$, $a'$ and $b'$ can be derived according to experimental data [16].

The $\frac{b(V)}{T^2}$ expression in equation 6 represents the non-Arrhenius behavior of temperature [17] [18].
5.3 Hot carrier injection

Hot carriers in a semiconductor device are the cause of a distinct wear out mechanism, the Hot Carrier Injection (HCI). Hot carriers are produced when the source-drain current flowing through the channel attains high energy beyond the lattice temperature. Some of these hot carriers gain enough energy, higher than the Si-SiO\(_2\) energy barrier of about 3.7 eV, to be injected into the gate oxide, resulting in charge trap and interface state generation. The latter may lead to shifts in the performance characteristics of the device:

- threshold voltage
- transconductance
- saturation current. [9, pp. 95]

The hot carrier effect accelerates as the temperature decreases. Hot carrier phenomena are accelerated by low temperature, mainly because this condition reduces charge de-trapping. [19]

A simple acceleration model for hot carrier effects is as follows:

\[
AF = \frac{t_{50(2)}}{t_{50(1)}},
\]

\[
AF = \exp\left(\frac{E_a}{kT} \left(\frac{1}{T_1} - \frac{1}{T_2}\right) + C(V_2 - V_1)\right),
\]

where, \(AF\) is the acceleration factor of the mechanism. \(t_{50(1)}\) and \(t_{50(2)}\) are the rates at which the hot carrier effects occur under conditions \(V_1\) and \(T_1\) and \(V_2\) and \(T_2\), respectively. \(T_1\) and \(T_2\) are the applied temperatures in Kelvins. \(E_a\) is the activation energy in the range of -0.2 eV to -0.06 eV and \(C\) is a constant. [20]

5.4 Electromigration

Electrons passing through a conductor transfer some of their momentum to its atoms. At sufficiently high electron current densities, greater than 105 A/cm\(^2\) [21], atoms may shift towards the anode side. The material depletion at the cathode side causes circuit damage due to decreased electrical conductance and eventual formation of open circuit conditions. This is caused by voids and micro-cracks, which may increase the conductor resistance as the cross sectional area is reduced. The mechanism for this is shown in Figure 9. Increased resistance alone may result in device failure, but also the resulting increase in local current density and temperature may lead to thermal runaway and failure, such as an open circuit. Alternatively, short circuit conditions may develop due to excess material buildup at the anode. Hillocks form where there is excess material, breaking the oxide layer and allowing the conductor to come in contact with other device features. Other types of damage
include whiskers, thinning, localized heating, and cracking of the passivation and inter level dielectrics [22].

This diffusive process, known as electromigration, is still a major reliability concern despite vast scientific research, as well as electrical and materials engineering efforts. In particular, the areas of greatest concern are the thin-film metallic interconnects between device features, contacts and vias [22].

The favored method to predict time-to-failure is an approximate statistical one given by Blacks equation, which calculates the MTTF as:

$$MTTF = AJ^{-n} \exp \left( \frac{E_a}{kT} \right),$$

where $A$ is constant based on cross-sectional area of the interconnect, $J$ is current density, $n$ is scaling factor, $E_a$ is EM activation energy, $k$ is Boltzmann’s constant, and $T$ is temperature in Kelvins [9, pp. 117].

### 5.5 Soft errors due to memory alpha particles

One of the problems which hinders development of larger memory sizes or the miniaturization of memory cells is the occurrence of soft errors due to alpha particles. Uranium (U) and thorium (Th) are contained in very low concentrations in package materials and emit alpha particles that enter the memory chip and generate a large concentration of electron-hole pairs in the silicon substrate. This causes a change in the electric potential distribution of the memory device amounting to electrical noise which, in turn, can cause changes in the stored information. Inversion of memory information is shown in Figure 10. The generated holes are pulled towards
the substrate with its applied negative potential. Conversely, electrons are pulled to the data storage node with its applied positive potential. A dynamic memory filled with charge has a data value of zero. An empty or discharged cell has a value of one. Therefore, a data change of 1-0 occurs when electrons collect in the data storage node. Such a malfunction is called memory cell model of a soft error. [9, pp. 119]

![Memory cell model of soft error](image)

**Figure 10:** Memory cell model of soft error [9, pp. 119].

The bit line model reflects a change of the bit line electric potential. The electric potential of the bit line varies with the data in the memory cell during readout, and is compared with the reference potential, resulting in a data value of 1 or 0. A sense amplifier is used to amplify the minute amount of change. If $\alpha$-particles penetrate the area near the bit path during the minimal time between memory readout and sense amplification, the bit path potential changes. An information
1-0 operation error results when the bit path potential falls below the reference potential. Conversely, if the reference potential drops, an information 0-1 operation error results. The memory cell model applies only to information 1-0 reversal, while the bit path model covers both information 1-0 and 0-1 reversals. The generation rate of the memory cell model is independent of the memory cycle time because memory cell data turns over. Since the bit path model describes problems that occur only when the bit line is floating after data read-out, an increased frequency of data read-out increases the potential for soft errors and so the bit path model occurrence rate is inversely proportional to the cycle time. In products, the combined model describes the combination of the memory cell and bit path models. [9, pp. 120]

5.6 IC design related failure mechanisms

IC chip edge cracks may be due to a too small tolerance in distance between the chip edges and the lid of a hermetically sealed component. The edges may be cracked at the sealing operation. Edge cracks may also develop due to improper chip bonding. Reference [23] reports that a bad soldering mostly results in edge cracks. The sensitivity for cracks decreases for thinner chips to a certain limit and increases with larger surface area. The best stress type for precipitation of this kind of weakness is thermal shock. [24, pp. 25]

Moisture in IC package can cause it to crack. When temperature is increased moisture evaporates and creates pressure which may cause a crack in the IC package. This can happen while soldering if the IC package has, at some point, absorbed moisture for example during storage. [4, pp. 463]

Moisture condenses onto surfaces when temperature drops to the dew point. Liquid water can cause chemical corrosion, [25, pp. 31-32] if contamination is also present, electrolytic corrosion and short-circuiting of electrical systems.

5.7 Manufacture related failure mechanisms

Manufacturing and assembly processes and procedures must be carefully controlled to ensure the reliability of the electronic equipment. Many early field failures in military electronic equipment have been traced back to manufacturing methods that are not normally evaluated in the preliminary design and analysis evaluations. Some of these documented failures are described below.

Conformal coatings are used to protect the electronics from moisture, salt and dirt. The coating can fill in under chip components and large fine-pitch surface mounted components. Chip resistors and capacitors and solder joints on the fine-pitch components may crack, due to thermal expansion in thermal cycling conditions. [7, pp. 340]

Large components will generate large relative displacement to the PCB as the PCB
bends during vibration. This increases strain and stress in the component lead wires. [7, pp. 339]

Wave soldering operation is known to lift some components up from the PCB. This produces tilted axial leaded component that has one long and one short lead. This solder wicking structurally short circuits the shorter wire strain relief. This increases the forces and stresses in the solder joint, which reduces the operating life. [7, pp. 337]

As through-hole components have been largely replaced by surface mount components, wave soldering has been supplanted by reflow soldering methods in many large-scale electronics applications. However, there is still significant wave soldering where SMT is not suitable (e.g. large power devices and high pin count connectors), or where simple through-hole technology prevails. [26]

Lead forming dies are used to bend the component lead wires to fit the solder pads. If dies are worn or they are not aligned properly, the lead wires may have sharp-bend radii, deep cuts or scratches. High stress concentrations are developed at these defects, which result in reduced operating life. [7, pp. 337]

Some through-hole components, such as, transformers, must not be flush mounted on PCBs. There is no air gap between the transformer and the PCB and it is difficult to clean out the solder paste and flux under the component. High humidity and a little electric current can promote dendritic growth under the component. This growth is a transparent semiconductor, similar in appearance to lacquer or shellac, with a high electrical impedance so high-impedance circuits can be affected by this growth. Another reason for not to flush mount is that the component may prevent the venting action of the hot gases escaping from the plated through-hole during the wave soldering operation. This builds up the air pressure in the plated through-hole, which reduces the wicking action of the solder. Plated through-holes are not full of solder and this causes premature solder joint failures. [7, pp. 337]

Components with flat bottom, like transformers, should not be mounted tightly on PCB. Thermal expansion in the transformer body in the direction perpendicular to the plane of the PCB can break the lead wires and solder joints in thermal cycling conditions. [7, pp. 340]

The copper layers must be located uniformly through multilayer PCBs to prevent them from warping during the lamination process and during the soldering process. Special fixtures may have to fabricated to prevent the PCBs from warping. High stresses can be developed in the component lead wires and solder joints if the PCBs are allowed to warp, which can lead to premature field failures. [7, pp. 338]

Components and PCB have different thermal coefficient of expansion (TCE). There is temperature difference when the component is turned on and it heats up faster than PCB. Shear stresses are imparted to solder joints. The bigger the component is the higher is the stress in the solder joints on the edge and especially on the corners of the component. This can cause deformation and fatigue failures in form of cracks in the solder joints. [4, pp. 430]
6 Accelerated stress testing

Stress testing can be implemented in different stages of a product life cycle - from the design qualification phase to the on-going testing at the stage of production. The most important stage of doing it is the design qualification because the benefits are realized over the whole life of the product. After the design stage manufacturing qualification stress testing is done to representative sample of product in order to identify deficiencies in component quality and manufacturing process, so that these deficiencies are fixed before production volumes become large. Production sampling or stress screening is performed regularly in order to monitor the production process for manufacturing and component quality variations. [27, pp. 9]

Accelerated stress testing (AST) is a reliability testing method that tries to induce failures in order to find weaknesses and fix those weaknesses to enhance the reliability. This testing differs from the classical reliability demonstration and mean time between failures (MTBF) types of tests that measure the expected life time of the UUT.

In AST the stress is increased over the normal operation conditions of the equipment. The reason for using higher stresses than in the actual service environment is to induce failures quickly. The failures that occurred during testing might occur in normal use as well. By investigating the physical and chemical background of the failures during testing might give the information whether these are relevant failures or not and how the durability of the equipment can be improved. Wrong conclusions about the nature of the failure lead to unnecessary improvements of the product and increased production costs.

The first thing in performing an AST is to determine, as far as practicable, what failures might occur in service. This should have been performed during design analysis and review, particularly during the quality function deployment (QFD) and failure modes, effects and criticality analysis (FMECA). After that the application and environmental stresses that could cause failures should be listed. Finally a plan is made on how to use stresses to stimulate foreseeable and unforeseen failures effectively and how the test set up is built, operated and monitored. [3, pp. 331-332]

The main reliability-affecting environmental factors, affecting most electronic products, are:

- temperature
- vibration
- shock
- humidity
- power input and output
- dirt
Different stress types can be applied simultaneously or separately to the equipment under test. The former is the better way because the total stress is higher and more failure mechanisms may be excited than when single stress is applied. There are chambers that can apply temperature cycling, humidity and vibration at the same time. Downside of these multi-stress is their high cost. [3, pp. 330-331]

Electronic systems have been subjected to accelerated temperature and vibration stresses to levels of the order of [3, pp. 330] 20-50 percent above specifications in development and for production units. Accelerated tests with stresses above the use environment are used and justified because the causes and probabilities of failures that will occur in the future are often very uncertain. It is possible that weakness is exposed during testing with different stress [5, pp. 140-142] than the one that would make the weakness show up in the field.

6.1 Highly accelerated life testing

Highly accelerated life testing (HALT) was developed by Dr. Gregg Hobbs and the principle of this concept is described fully in reference [5].

In HALT, as well as in ALT, the goal is to simulate the life time stresses a product is going to experience. These two concepts differ two ways from each other. Firstly, HALT uses higher stress levels than in ALT in order to gain more life time compression. Secondly HALT is not for measuring the expected life of the product but, like in AST, to induce failures to find weaknesses. Different types of testing like temperature cycle, humidity, vibration and product specific stresses like power cycling and varying input line voltage can be part of HALT program. In testing program, for example for a printer, can be included tests where shafts or bearings are misaligned or papers are used that are out of specification dimensions or have frictions. [5, pp. 49]

6.2 Step-stress testing

Step-stress testing has been used since the early days of space program. This test is categorized as highly accelerated stress test (HAST) because of its nature. Step-stress testing starting point is a known stress level and then increasing the stress levels in controlled steps. At each stress level tests are run in order to monitor functionality and performance of the equipment under test. This process is repeated until equipment under test fails or satisfactory stress level is achieved. [27, pp. 11]

Figure 11 illustrates the process of step-stress testing. The stress is increased further with higher stress than the product is designed to withstand and failure at some
point is expected. The reason for failure is analysed. The relevance of the failure must be considered because it is useless to change design if it is very unlikely to have a failure of this type in normal use. If irrelevant failures begin to appear step-stress testing is not useful.

### 6.3 Value of stress testing

It has been found in various papers from Hewlett-Packard that most of the weaknesses found in HALT and not addressed resulted in costs to the company in the neighbourhood of 10 million US$ to address later, when failure costs were included. [28]

Time spent to testing is expensive, so the more quickly we can find possible causes of failures the better. Finding causes of failure during development and preventing recurrence is far less expensive than finding new failure causes in use.

Direct costs of failure of a product that is already in the market are reclamation requests, alternation of the production line for replacement component or unit, substituting the stock of failure sensitive components or units with new ones, testing the product with new component or unit and the delay caused by the measures discussed. Indirect cost is decreased customer confidence in the market. Buyers want to have reliable equipment in order to keep the maintenance costs as low as possible. Reliability of the product is an essential marketing medium.
6.4 Stress screening

Stress screen testing removes the units not qualified for sale and prevents early failures in use. Defective components or mistakes during manufacturing may result in very weak units. Even a small imperfection like voids in solder joint may cause the stress concentration in that particular location to increase by a factor of two to three compared to a flawless solder joint. Units with imperfections will fail quickly in use conditions. This is also known as ‘infant mortality’.

Fatigue damage is cumulative, as was mentioned earlier in this thesis, and so stress screening removes some life from the product. However stress screen testing doesn’t have much effect on healthy products. If assumed that there is a flaw which causes the stress concentration to increase by a factor of two. According to the Miner’s equation (3) with material property $\beta$ assumed to be about 10, the fatigue damage would accumulate about 1000 times as fast in the area with the flaw as it would in a non-flawed location having the same nominal stress level. This means that the flawed area can break and the non-flawed areas still have 99.9% of the life left. [5, pp. 16]

The amount of life in a product after the screen test compared to the initial state of the product can be measured by performing the screen testing many times for a couple of products. If a product can handle, let’s say 20 screen tests, as in Figure 12 without an end-of-life failure then after one screen test there is still at least 95% of the life time left in the product. Also performing many screen tests ensures that the test itself doesn’t initiate a defect like a crack which would make the product deteriorate much faster than without testing it in the first place. [5, pp. 104-107]

![Figure 12: Validating stress screen test which is to be used in production [5, pp. 106].](image)

```plaintext
select stresses -> perform HASS -> end of life failures ?

no, 20 repeats ?

no

yes, decrease appropriate stress

start production HASS
```
6.5 Accelerated life testing

Accelerated life testing (ALT) measures the expected life of the equipment by simulating a lifetime of the actual stresses the product will experience. This testing method is used in the product reliability validation to ensure acceptable lifetime in use. The concept of ALT is pretty much the same as that of AST but in addition there is an acceleration factor (AF) that relates the mean time to failure (MTTF) of equipment in normal use and equipment under test. Acceleration factor, which is calculated in Equation (10), is the equipment MTTF in normal use environment divided by MTTF under test conditions.

\[
AF = \frac{MTTF_{\text{in use}}}{MTTF_{\text{undertest}}} \tag{10}
\]

In general, accelerated life testing techniques provide a shortcut to investigate the reliability of electronic devices with respect to certain dominant failure mechanisms occurring under normal operating conditions. Accelerated tests are usually planned based on the assumption that there is a single dominant failure mechanism for a given device. However, the failure mechanisms that are dormant under normal use conditions may start contributing to device failure under accelerated conditions, and the life test data obtained from the accelerated test would, therefore, not be representative of the actual situation. Moreover, an accelerated stress accelerates various failure mechanisms simultaneously and the dominant failure mechanism is the one which gives the shortest predicted life. [29]

6.6 Temperature cycle testing

Temperature cycle is one of the most common ways of doing AST. Temperature cycling can be done in thermal chambers. Key parameters are not only high and low temperature but also temperature change rate and dwell time.

![Temperature cycle with UUT](image-url)

Figure 13: Temperature cycle with UUT.
Temperatures of a climatic chamber and operating UUT is sketched in Figure 13. Temperature inside the UUT is higher than the ambient temperature because it is operating and produces some heat. The temperature change rate of the UUT is lower than the one of the climatic chamber and reaches its maximum when the climatic chamber reaches its maximum or minimum temperature. Temperature maximum and minimum are chosen according to the use environment of the equipment and used testing method.

Dwell time ensures that inside the UUT the temperature reaches stable state after the chamber has reached the maximum or minimum temperature of the cycle. Dwell time depends on the structure of the equipment. Required dwell time can be measured by applying a temperature sensor in the UUT and taking time when temperature change is near zero. If the equipment is sealed, dwell time is longer than when it has ventilation holes and possibly fans.

6.6.1 Temperature shock

Temperature shock can be arranged switching high power equipment on and off or by using two climatic chambers, one with high temperature and the other with low temperature, and quickly moving the UUT from one chamber to another.

6.6.2 Stress effects

High temperature causes:

- softening and weakening (metals, some plastics)
- melting (metals, some plastics)
- charring (plastics, organic materials)
- other chemical changes
- reduced viscosity or loss of lubricants
- interaction effects, such as temperature-accelerated corrosion.

Low temperature effects are:

- embrittlement of plastics
- increased viscosity of lubricants
- condensation
- freezing of condensation or coolants.
Most of these temperature effects are deterministic not cumulative, so time and number of cycles do not directly affect reliability. However, secondary effects might be cumulative, for example the effects of lubricant viscosity on rate of wear. Possible stress screen types for precipitate solder joint cracks are vibration and temperature cycling. [24, pp. 39]

6.7 Vibration testing

Single frequency sinusoidal wave test can be used to test the equipment compatibility with some source of constant frequency vibration like a constant speed rotating motor. Single frequency vibration can be also used to excitate the resonance frequencies of the equipment one at a time and checking if there is some resonance frequency to which it is vulnerable. This test type is specifically used in development phase.

Sinusoidal vibration sweep over frequency range can reveal resonance frequencies in the system. Key parameters are acceleration, frequency range, number of sweeps and sweep rate, which is usually expressed as octave per minute.

Random frequency vibration testing is used to simulate the use environment. This test type is used in qualification, reliability and acceptance testing. The amount of vibration is usually expressed as acceleration spectral density (ASD). Other parameters are random vibration frequency bandwidth and attenuation outside the bandwidth, which is usually expressed as attenuation in decibels per octave from the boundary frequency.

Test systems can usually vibrate along one axis on both directions, so all three different axes of the UUT has to be tested separately. Multi-axis vibration test systems are more expensive than single axis ones.

Dr Gregg Hobbs, who introduced the HALT, claims that he first used single axis vibration machine to severely ruggedize a device. Then, in production, a multi-axis vibration machine was used and three design weaknesses which had not been found on the single-axis system were exposed almost immediately. [5, pp. 18]

With high acceleration levels relays chatter and crystal oscillator signal may be distorted when their internal resonance are excited. These are soft failures if the UUT works normally after the vibration is stopped. Typical hard failures include cracked solder joints, broken wires, cracked circuit traces, cracked plated through-holes, broken connector pins, broken screws, cracked components, cracked hermetic seals, and cracked silicon chips. [7, pp. 189]

6.8 Mechanical shock testing

Shock is defined as a rapid transfer of energy to a mechanical system, which results in a significant increase in the stress, velocity, acceleration or displacement within the system. [7, pp. 248]
A common way of doing shock testing is dropping the equipment. Test subject is attached to a plane, which is then dropped to hit rubber pads or a spring that bounces the plane and its velocity goes abruptly to zero. Key parameters for this test are drop height, rubber pad elasticity or spring rebound coefficient.

Shock and vibration testing failures are very similar. Shocks can produce four basic kind of failures in electronic systems

- high stresses, which can cause fractures or permanent deformations in the structure
- high acceleration levels, which can cause relays to chatter, signal distortion in crystal oscillators, potentiometers to slip and bolts to loosen
- high displacements, which cause impact between circuit board and adjacent board or shell causing electrical malfunction such as short-circuit or cracking components and solder joints. [7, pp. 248]
7 Microwave radio link

Microwave radio link is mainly used in macrocellular sites. It can also be used in the microcell layer when there is a need for higher capacities or longer radio hops. Microwave radio link main parts are indoor unit, outdoor unit, and antenna.

Indoor unit is connected to outdoor unit with coaxial cable which transfers data in full duplex mode and feeds DC power to the outdoor unit from indoor unit. Several outdoor units can be attached to single indoor unit. Also indoor units can be attached to another indoor unit with the same cable. In Figure 14 there is an example configuration of branching station with two indoor units and four outdoor units directly attached to the antennas.

![Figure 14: Radio link configuration [30].](image)

7.1 Outdoor unit

Microwave radio is the part that sends and receives transmission. Bi-directional communication can be realized with two techniques:

- Time division duplex (TDD), which means that the transmission and reception are done at different times.

- Frequency division duplex (FDD), which means that the received and transmitted signals are on different frequency bands. Difference between received and transmitted signal is called duplex frequency.

There are different ways to divide the functionalities between outdoor and indoor unit. In Figure 15 the modem is located in the outdoor unit. It may also be in the indoor unit and the data flows through I/Q-channel between outdoor and indoor units.
7.1.1 NSN Flexi Hopper Plus design

Block diagram of the Flexi hopper plus microwave radio outdoor unit is illustrated in Figure 15.

Figure 15: Block diagram of the outdoor unit [30].

The outdoor unit includes five functional units:

- a power supply unit (PSU)
- a modem board
- an intermediate frequency unit (IFU)
- a microwave unit (MWU)
- a duplex filter.

Moving modem to outdoor unit decreases the reliability of the outdoor unit. Upside of this is that there is less attenuation between the modem and the IF unit resulting increased hop length of the radio link.

The main component of the modem board is the custom design ASIC (application-specific integrated circuit). The ASIC contains a digital modulator and demodulator with Reed-Solomon forward error correction (FEC). The interface between the modem board and the RF part is analog I and Q signals. The modem board also includes an embedded microprocessor system, which is used to control all units inside the outdoor unit as well as to communicate with the indoor unit and the far-end unit when needed. The RF functions are divided between two units: the IF unit and the microwave unit. The MWU includes all microwave circuits, most of which are MMICs, while the IFU includes required intermediate frequency circuits. The
waveguide duplex filter separates the transmitter and the receiver and provides at the same time low loss connection to the antenna port. [30]

In the transmitter side, direct conversion architecture has been implemented to enable use of a single microwave local oscillator. Since the I/Q up-converter operates at the end frequency, a digital feedback loop is required to correct the amplitude and phase errors of the modulator. After the up-conversion the signal is amplified enough in order to obtain the required maximum output power level. A temperature compensated power detector is used to monitor the power level after the high power amplifier (HPA), and thus, to drive the voltage variable attenuator (VVA) in order to obtain the required output power level. [30]

In the receiver side, the single IF conversion architecture is used. After the low-noise amplifier (LNA) the received signal is down-converted to the IF. The automatic gain control (AGC) with a dynamic range of about 100 dB is used to obtain a constant rms-power level for the I/Q-demodulator. The outdoor unit contains two separate phase-locked oscillator circuits. In the MWU, the fundamental oscillator frequency is multiplied in order to obtain the low phase noise VCO signal for the transmitter (Tx) and the receiver (Rx) up- and down-converters. Due to the common VCO frequency at Tx and Rx, the IF frequency is always equal to the duplex spacing. [30]

The transmitter uses either 4-state modulation (π/4-DQPSK, differential quadrature phase shift keying) or optional 16-state modulation (32 TCM, Trellis coded modulation), which have the advantages of a narrow spectrum and a good output power efficiency. The optional 16-state modulation is available for 8x2 and 16x2 Mbit/s capacities. The channel bandwidth is half of the bandwidth required for the 4-state modulation with the same capacity. 4-state modulation has 2x2, 4x2, 8x2 and 16x2 Mbit/s capacities.
8 Reliability testing of microwave radio outdoor units

Reliability testing process consists of calibration of the test system, measurements before and after the stress cycle, stress cycle and overview of the results. Performance measurements before the stress cycle ensure that the equipment under test meets its specifications. Comparing measurement results that were obtained before and after the stress cycle with one another gives information about the deterioration of the equipment during stress cycle.

8.1 Pre- and post- stress cycle measurements

The main goal of these pre- and post-measurements is to measure the performance of the outdoor unit and locate the malfunctioning blocks. This is achieved by doing several tests. On one test run these test cases are repeated several times with different outdoor unit transmission settings and with different temperatures to ensure that the UUT can operate in the specified temperature range. Test cases for microwave radio outdoor unit are:

- BER compared to input signal power level
- spectrum of TX signal
- accuracy of TX signal power
- accuracy of TX carrier frequency
- spurious emissions
- accuracy of RX signal power measurement.

Test setup consists of waveguides, couplers, variable attenuators and measurement equipment. A sketch of the test setup is shown in Figure 16. Following equipment are needed to perform test cases that were mentioned in previous chapter:

- power meter and two power sensors
- spectrum analyzer
- attenuator control processor and two variable attenuators
- BER meter (Another BER meter is required if TX bit errors are measured during stress cycle)
- climatic chamber.
Measurements are usually done in at least two temperatures. If the stress is inflicted to the unit under test by temperature cycle, then the pre- and post-measurements are done at the maximum and the minimum temperatures of the cycle. Moreover, the measurements may also be done at room temperature. The outdoor unit has several capacities and modulations. Each combination of these capacities and modulations has to be tested separately at every testing temperature.

8.1.1 RX BER compared to input signal power level

This test measures the receiver sensitivity of the UUT. Sensitivity is the smallest RX signal power level the UUT can receive without bit errors. The smaller the sensitivity is the more attenuation is acceptable between two microwave radios.

A transmission analyzer and two power meters are required for this test case. RX-signal of the UUT is attenuated and at some point the BER increases rapidly. Attenuation is adjusted to find out the RX-signal levels where the BER is $10^{-6}$ and $10^{-3}$. This test can be performed also increasing attenuation step by step. RX-signal level can be counted from the TX signal power of the reference unit subtracted with the total attenuation when decibel scale is used. [31]

8.1.2 Spectrum of TX signal

This test measures the TX signal spectrum. The main concerns are usually too high sidebands, IF harmonics and too high noise floor.
For this test case a spectrum analyzer is needed. TX signal from the UUT is led to the spectrum analyzer which measures its spectrum over the signal bandwidth. The spectrum is compared to a mask which sets the limits it must not exceed. [31]

8.1.3 Accuracy of TX signal power

TX signal power level can be chosen manually or controlled automatically according to the radio link attenuation. It is adjusted through a loop-back to match the nominal value.

TX signal power of the UUT is measured with power meter. Different combinations of nominal output power levels and TX frequencies are used and with every combination the real output power of the UUT is measured. These real output powers are then compared with the nominal values. [31]

8.1.4 Accuracy of TX carrier frequency

TX carrier frequency is mixed with the IF signal. Carrier frequency determines the transmission frequency over a hop.

The microwave radio transmits only the carrier frequency, if the modulation of the radio is turned off. The carrier frequency can then be measured with a frequency counter or spectrum analyzer. The result is then compared to the nominal value of the TX carrier frequency. [31]

8.1.5 Spurious emissions

Spurious emissions are unwanted transmitted signals outside the transmission bandwidth. These can be harmonic signals due to mixer LO leakages and improper filtering.

For this test case a spectrum analyzer is needed. TX signal from the UUT is fed to the spectrum analyzer. Several frequency sweeps are taken with the spectrum analyzer so that the whole measurement band gets swept with right spectrum settings. The frequencies that are included in these sweeps are from waveguide cutoff frequency up to the second harmonic of the TX carrier frequency. The bandwidth used in measurement of TX signal spectrum mask is excluded from this measurement. The spectrum analyzer may also limit the upper boundary of the frequency sweep when high-frequency microwave radios are tested. [31]

8.1.6 Accuracy of RX signal power measurement

The RX signal power has to be adjusted to certain level before it can be fed to demodulator. The adjustment is done with an AGC amplifier in the IF unit.
The reference unit is set to transmit signal, which is fed through the waveguides to the UUT. Outdoor units have inbuilt power meter to detect the incoming signal power level. This signal power is compared to the real RX signal power, which is counted from the power meter value and calibration data. [31]

8.2 Analyzing test results

The same set of measurements are done before and after stress cycle. Test results are compared to specifications and also with each other. The comparison has to be profound. Usually even small differences in the pre- and post-measurement results indicate fast deterioration of some component in the UUT. [31]

Each test case has its specifications the measurement results has to fulfill otherwise the test fails. The reason to mark a test as failed and some examples of possible failure reason for each test case are listed in Table 1.

Failed test cases and differences between pre- and post-measurements might originate also from malfunctioning of a measurement equipment. To ensure that the test result is genuine the test or part of it can be done manually or the test case can be rerun. Also possibility of human error has to be considered.
Table 1: Failure reasons for test cases.

<table>
<thead>
<tr>
<th>Test case</th>
<th>Reason to fail the test</th>
<th>Example of failure reason</th>
</tr>
</thead>
<tbody>
<tr>
<td>RX BER</td>
<td>The RX signal power is higher than in specifications for BER of $10^{-6}$ or $10^{-3}$.</td>
<td>Something is wrong with the RX signal path (e.g. in LNA) that causes either noise floor to rise or the RX signal to attenuate too much.</td>
</tr>
<tr>
<td>Accuracy of RX signal power measurement</td>
<td>The signal power measured by UUT differs too much from the real value.</td>
<td>The detector diode may be broken or calibration coefficients, that convert the detector values to power values, are inaccurate.</td>
</tr>
<tr>
<td>Spurious emissions</td>
<td>UUT transmits signals outside the TX bandwidth that have higher power than specification approves.</td>
<td>The filtering is not good enough or there are some LO-leakages that cause harmonic signals.</td>
</tr>
<tr>
<td>Spectrum of TX signal</td>
<td>The spectrum exceeds the mask.</td>
<td>In mixer the signal can degrade which may lead to symbol frequency harmonic signals.</td>
</tr>
<tr>
<td>Accuracy of TX signal power</td>
<td>TX signal power differs too much from the nominal power.</td>
<td>Something is wrong with the power adjustment loop or detector diode.</td>
</tr>
<tr>
<td>Accuracy of TX carrier frequency</td>
<td>Unmodulated carrier frequency differs too much from the nominal TX frequency.</td>
<td>Crystal oscillator tuning has changed. Also aging causes change in crystal oscillator frequency.</td>
</tr>
</tbody>
</table>
9 Problem definition

Reliability testing is time consuming process and is practically the last step a product has to pass before it can be sold in the market. Telecommunication is a big business and while technological development goes forward, new products and new versions are been developed. Time from sketch board to market is essential factor when the profitability of a new project is considered and whether it is launched or not.

Starting reliability testing in a new production facility may be a slow process. Resources are needed for new equipment and for hiring and training new personnel. When things are up and running it takes some time before personnel gains experience so that testing runs smoothly. Also human errors decrease over time, but the more complex the testing process is the more prone it is to errors. Undetected errors, whether during measurement or in calculations, lead to incorrect test results. If these errors are undetected also in result review, the worst thing that can happen is that the design of the tested product is changed according to these false results.

9.1 Work assignment

Work assignment includes further developing reliability testing automation for Flexi-Hopper Plus outdoor unit by adding two new test cases to an already existing test automation and enhancing the functionality of the test automation. The main objective is to reduce the amount of manual work and speed up reliability testing of the outdoor units.

The existing test automation provides the system architecture and the following test cases:

- BER compared to input signal power level
- spectrum of TX signal
- accuracy of TX signal power
- accuracy of RX signal power measurement.

The following test cases are to be added to the test automation:

- accuracy of TX carrier frequency
- spurious emissions.

Following ideas were presented considering the new test automation:

- Test automation should be able to control measurement equipments and climatic chamber.
- Test automation handles measurements done before and after the stress cycle.

- Test engineer needs to attach radios to calibrated test setup, select correct calibration data, select test plan and press "START".

- Results are stored to database from where results can be extracted as reports for the review.

- Test automation should be able to be copied to a new location.

- Test engineer doesn’t need to be "expert" in reliability testing.

- Modularity of the test automation is important in order to be able implement it for testing of different types of radios. [32]
10 Test automation architecture

Main parts of the test automation are:

- Teststand that reads configuration information from files and user input, controls the automation process, calls VEE-programs and stores test results to a database.

- Agilent Vee Pro that works as a run-time environment for VEE-programs. VEE-programs send commands to measurement equipments and climatic chamber and get output from them.

- Database where the results are stored.

- Reporting tool that extracts the results from database to printable version.

![Diagram of test automation architecture]

Figure 17: Test automation architecture.

10.1 Teststand - test sequence editor

Teststand is a software that controls the execution of tests. The Teststand engine, as shown in Figure 18, plays a pivotal role in the Teststand architecture. The Teststand engine can run sequences. Sequences contain steps that can call external code modules. By using module adapters that have a standard adapter interface, the Teststand engine can load and execute different types of code modules. Teststand sequences can call subsequences through the same adapter interface. Teststand uses a special type of sequence called a process model to direct the high-level sequence flow. The Teststand engine exports an ActiveX Automation API that the Teststand sequence editor and run-time operator interfaces use. [33]
Teststand sequence editor is an application program in which the sequences can be created, modified, executed and debugged. Teststand run-time operator interfaces are simpler than the editor and don’t allow meddling with the sequence file. There are four different run-time operator interfaces and they are developed in LabVIEW, LabWindows/CVI, Visual Basic and Delphi.

Most steps in a Teststand sequence invoke code in another sequence or in a code module. When invoking code in a code module, Teststand must know the type of code module, how to call it and how to pass parameters to it. Teststand uses module adapters to obtain this knowledge. Teststand currently provide module adapters for following programming environments:

- LabWindows/CVI
- Visual C/C++
- .NET
- C DLLs
- Java classes
- HTBasic
- TCL
- PERL
- VEE. [33]
The test management system must also perform a series of operations before and after the test sequence executes to handle common test system tasks. These operations define the testing process, and the set of operations and the flow of execution is called a process model. With process models different test sequences can be written without repeating standard testing operations in each sequence. The process model can be modified to vary the testing process to suit the unique needs of a production line. Figure 19 contains a flowchart of the major operations in the default process model. [33]

![Flowchart of the major operations in the default process model.](image)

Figure 19: Teststand default process model.
10.2 Visual engineering environment

Agilent visual engineering environment (VEE) is a visual programming language environment. VEE supports standard ties to ActiveX Automation and Controls, and DLLs. Therefore it can be used from Teststand through ActiveX Automation adapter.

VEE programs are created by selecting objects from menus and connecting them together. The result in VEE resembles a data flow diagram, which helps understanding the code. In figure 20 there is an example of a simple VEE program.

![Figure 20: "Random" program in VEE.](image)

In VEE, data moves from one object to the next object in a consistent way: data input on the left, data output on the right, and operational sequence pins, which control the execution order of the objects, on the top and bottom.

10.2.1 Communication with measurement equipment

Professional measurement equipments, like spectrum analyzers, power meters, bit-error-ratio meters and so on, come with possibility to control them remotely via various physical interfaces. Most common interface buses are General purpose interface bus (GPIB) and serial communication bus. RS-232 type of serial interface port is common in personal computers and climatic chambers. Climatic chambers can usually be programmed to perform a temperature cycle.

Installation of Agilent IO libraries suite software is required if Agilent VEE has to control measurement instruments. Agilent VEE supports GPIB, VXI, serial, GPIO, and LAN interfaces for communicating with measurement instruments.
11 Implementation of the automation software

The master’s thesis work assignment was to implement two new test cases, accuracy of TX carrier frequency and spurious emissions, to an existing automation software which is for reliability testing of the FlexiHopper Plus microwave radio outdoor unit. I was familiar with the test cases, because I had already worked the previous summer as an intern doing reliability testing. The automation development tools, Teststand and VEE Pro, I had never used before. I had some programming background and with help from a colleague I learned the basics of these development tools pretty quickly.

The development process wasn’t as straightforward as I first thought it would be. Controlling the measurement equipment and climatic chamber through direct I/O interface, which specifies the communication transaction in detail, turned out to be the most difficult part of the project. Although the old test automation had been in use for some time without any significant errors, there were run-time errors when I ran the old test automation in my development setup. The problem appeared when a query was sent to a climatic chamber or spectrum analyzer and run-time error occurred because answer was not received. First I thought that the problem was mismatch of the VEE Pro version. The old automation had used version 6.5 of the VEE Pro and now my development setup had newer 8.5 version of the VEE Pro installed. In order to locate the cause of the problem I made a test code module. As the problem persisted even with the code module that was purely made with the newer version, it was obvious that the problem lied elsewhere. My colleague suggested that the root cause might be that the computer I used was newer and faster than the ones used with the old test automation. After sending a query to a climatic chamber or a spectrum analyzer, the computer waits for an answer. The time the computer waited for the answer is proportional to the clock rate of the CPU so the new computer didn’t wait long enough and read an empty answer from its receive buffer. The problem was solved by adding some delay between sending a query and reading the answer.

Altogether it took almost six months to get the project done. Two new test cases, spurious emissions and TX frequency accuracy, are now included as new test cases to the reliability test automation. Functionality of these new test cases and the whole test automation was checked with several trials. Trials were performed with two different frequency band, 8 GHz and 15 GHz, outdoor units. Test plan during trials consisted of all the test cases and three different temperatures. The test automation was started, left alone over night and the results were extracted from database on the following day. The automation worked as planned.

Alongside with the implementation of the test cases I studied reliability testing that contributed to the theory part of my master’s thesis.
12 Results

It takes about 55 minutes to run through every test case once with one capacity on one modulation. In Table 2 there are listed the times taken by the execution of the test cases. These times are not exact.

Table 2: Time taken by the execution of the test cases with one capacity and one modulation.

<table>
<thead>
<tr>
<th>Test case</th>
<th>Manual (min)</th>
<th>Automation (min)</th>
</tr>
</thead>
<tbody>
<tr>
<td>TX frequency accuracy</td>
<td>2</td>
<td>0.5</td>
</tr>
<tr>
<td>Spurious emissions</td>
<td>10</td>
<td>1</td>
</tr>
<tr>
<td>All test cases</td>
<td>N/A</td>
<td>55</td>
</tr>
</tbody>
</table>

The two new test cases are quickly done when automation is used. Manual execution of the test cases is a lot slower compared to automation. Usually every combination of the capacities and modulations are tested separately. The difference between execution times can be multiplied with the number of these combinations. There are six of these combinations in a FHP radio. Also the test automation can change the temperature of the climatic chamber. It takes up to an hour and a half to get the temperature inside the outdoor unit under test stable after the climatic chamber has reached its target temperature.
13 Conclusion

In this section the benefit of including the two test cases to the test automation is described and a future prospect is proposed.

Mainly the benefit comes from reduced manual work and execution time, because the test engineer doesn’t have to be present while the automation executes the test cases, and the whole test plan can be carried out over night or over weekend. Other benefits are:

- Automated test execution ensures that measurements have good reproducibility. This helps comparing the radios with one another.

- Manual execution is prone to human errors which may result in unnecessary re-testing or wrong conclusions.

- All the test case results are now stored in the same database that makes it easy to access them and extract reports.

Some future prospects came to my mind while doing this thesis work. This automation could be done without Teststand Sequence editor by replacing it with VEE code modules. This would make the test automation architecture seen in Figure 17 simpler and easier to adapt to new requirements. The usefulness of the Teststand is in the clear way of presenting the execution process in steps. Also Teststand handles database logging very well. The version 9.0 of the VEE Pro has in-built database handling and it could be possible to replicate the steps in Teststand.
References


## Appendix A: Typical examples of accelerated stress tests

<table>
<thead>
<tr>
<th>Applied stress method</th>
<th>Accelerated test</th>
<th>Main stressor</th>
<th>Failure mechanism</th>
</tr>
</thead>
<tbody>
<tr>
<td>Constant</td>
<td>High-temperature</td>
<td>Temperature</td>
<td>Junction degradation, impurities deposit, ohmic contact, inter-metallic chemical compounds</td>
</tr>
<tr>
<td></td>
<td>Operating life test</td>
<td>Temperature Voltage Current</td>
<td>Surface contamination, junction degradation, mobile ions, EMD</td>
</tr>
<tr>
<td></td>
<td>High temperature, high humidity storage</td>
<td>Temperature Humidity</td>
<td>Corrosion, surface contamination, pinhole</td>
</tr>
<tr>
<td></td>
<td>High temperature, high humidity bias</td>
<td>Temperature Humidity Voltage</td>
<td>Corrosion, surface contamination, junction degradation, mobile ions</td>
</tr>
<tr>
<td>Cyclic</td>
<td>Temperature cycle</td>
<td>Temperature difference Duty cycle</td>
<td>Cracks, thermal fatigue, broken wires and metallization</td>
</tr>
<tr>
<td></td>
<td>Power cycle</td>
<td>Temperature difference Duty cycle</td>
<td>Insufficient adhesive strength of ohmic contact</td>
</tr>
<tr>
<td></td>
<td>Temperature-Humidity cycle</td>
<td>Temperature difference Humidity difference</td>
<td>Corrosion, pinhole, surface contamination</td>
</tr>
<tr>
<td>Step stress</td>
<td>Operating test</td>
<td>Temperature Voltage Current</td>
<td>Surface contamination, junction degradation, mobile ions, EMD</td>
</tr>
<tr>
<td></td>
<td>High temperature reverse bias</td>
<td>Temperature Voltage</td>
<td>Surface contamination, junction degradation, mobile ions, TDDB</td>
</tr>
</tbody>
</table>
Appendix B: Frequently used acceleration models

<table>
<thead>
<tr>
<th>Description</th>
<th>Application</th>
<th>Model equation</th>
</tr>
</thead>
<tbody>
<tr>
<td>Arrhenius acceleration model</td>
<td>Life as a function of temperature or chemical aging</td>
<td>( Life = A_0 e^{\frac{-E_a}{kT}} ) where ( A_0 = ) scale factor determined by experiment, ( E_a = ) activation energy of the failure mechanism, ( k = ) Boltzmann’s constant, ( T = ) temperature (K)</td>
</tr>
<tr>
<td>Norris-Landzberg a.k.a. modified Coffin-Manson</td>
<td>Fatigue life of metals (due to thermal cycling and/or thermal shock)</td>
<td>( AF = \left( \frac{\Delta T_f}{\Delta T_l} \right)^{1.3} \left( \frac{f_f}{f_l} \right)^{1/3} \exp[1414 \frac{1}{T_{max_f}} - \frac{1}{T_{max_l}}] ) where ( AF = ) acceleration factor (cycle basis), ( \Delta T = ) package/board temperature difference between ( T_{on} ) and ( T_{off} ) (K), ( T_{max} = ) maximum solder joint temperature (K), ( f = ) cyclic frequency (cycles per 24h), Minimum number of six, ( f,f,l = ) subscripts to denote field and lab conditions respectively</td>
</tr>
<tr>
<td>Black</td>
<td>Life as a function of temperature and current density</td>
<td>( MTTF = A J^{-n} e^{\frac{E_a}{kT}} ) where ( A = ) constant based on cross-sectional area of the interconnect, ( J = ) current density, ( n = ) scaling factor, ( E_a = ) activation energy of the failure mechanism, ( k = ) Boltzmann’s constant, ( T = ) temperature (K)</td>
</tr>
<tr>
<td></td>
<td>Capacitors, electromigration in aluminium conductors</td>
<td></td>
</tr>
</tbody>
</table>
### Appendix C: The relation among failure modes, mechanisms and factors

<table>
<thead>
<tr>
<th>Failure Factors</th>
<th>Failure Modes</th>
<th>Failure Mechanisms</th>
</tr>
</thead>
<tbody>
<tr>
<td><strong>Diffusion</strong></td>
<td><strong>Substrate</strong></td>
<td>Crystal defect</td>
</tr>
<tr>
<td><strong>Junction</strong></td>
<td><strong>Diffused junction</strong></td>
<td>Impurity precipitation</td>
</tr>
<tr>
<td><strong>Isolation</strong></td>
<td><strong>Crystal defect</strong></td>
<td>Photoresist mask</td>
</tr>
<tr>
<td></td>
<td></td>
<td>misalignment</td>
</tr>
<tr>
<td></td>
<td></td>
<td>Surface contamination</td>
</tr>
<tr>
<td><strong>Oxide film</strong></td>
<td><strong>Gate oxide film</strong></td>
<td>Decreased breakdown voltage</td>
</tr>
<tr>
<td></td>
<td><strong>Field oxide film</strong></td>
<td>Short circuit</td>
</tr>
<tr>
<td></td>
<td></td>
<td>Increased leakage current</td>
</tr>
<tr>
<td><strong>Metallization</strong></td>
<td><strong>Interconnection</strong></td>
<td>Mobile ion</td>
</tr>
<tr>
<td><strong>Contact hole</strong></td>
<td><strong>Mechanical damage</strong></td>
<td>Pinhole</td>
</tr>
<tr>
<td><strong>Via hole</strong></td>
<td><strong>Non-ohmic contact</strong></td>
<td>Interface state</td>
</tr>
<tr>
<td></td>
<td></td>
<td>TDDDB</td>
</tr>
<tr>
<td></td>
<td></td>
<td>Hot carrier</td>
</tr>
<tr>
<td><strong>Passivation</strong></td>
<td><strong>Surface protection film</strong></td>
<td>Decreased breakdown voltage</td>
</tr>
<tr>
<td></td>
<td><strong>Interlayer dielectric film</strong></td>
<td>Short circuit</td>
</tr>
<tr>
<td></td>
<td></td>
<td>Increased leakage current</td>
</tr>
<tr>
<td></td>
<td></td>
<td>( h_{fe} ) and/or ( V_{th} ) drift</td>
</tr>
<tr>
<td><strong>Die bonding</strong></td>
<td><strong>Chip-frame connection</strong></td>
<td>Open circuit</td>
</tr>
<tr>
<td><strong>Wire bonding</strong></td>
<td><strong>Die attachment</strong></td>
<td>Short circuit</td>
</tr>
<tr>
<td><strong>connection</strong></td>
<td><strong>Die crack</strong></td>
<td>Increased leakage current</td>
</tr>
<tr>
<td><strong>Wire lead</strong></td>
<td></td>
<td>( h_{fe} ) drift</td>
</tr>
<tr>
<td></td>
<td></td>
<td>Noise deterioration</td>
</tr>
<tr>
<td><strong>Wire bonding</strong></td>
<td><strong>Wire bonding deviation</strong></td>
<td>Open circuit</td>
</tr>
<tr>
<td><strong>connection</strong></td>
<td><strong>Off-center wire bonding</strong></td>
<td>Short circuit</td>
</tr>
<tr>
<td><strong>Wire lead</strong></td>
<td><strong>Damage under wire bonding contact</strong></td>
<td>Increased leakage current</td>
</tr>
<tr>
<td></td>
<td><strong>Disconnection</strong></td>
<td>( h_{fe} ) drift</td>
</tr>
<tr>
<td></td>
<td><strong>Loose wire</strong></td>
<td>Noise deterioration</td>
</tr>
<tr>
<td></td>
<td><strong>Contact between wires</strong></td>
<td>Open circuit</td>
</tr>
<tr>
<td></td>
<td></td>
<td>Short circuit</td>
</tr>
<tr>
<td></td>
<td></td>
<td>Increased resistance</td>
</tr>
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</table>
Appendix D: The relation among failure modes, mechanisms and factors continued

<table>
<thead>
<tr>
<th>Failure Factors</th>
<th>Failure Modes</th>
<th>Failure Mechanisms</th>
</tr>
</thead>
<tbody>
<tr>
<td>Sealing</td>
<td>Resin</td>
<td>Void</td>
</tr>
<tr>
<td></td>
<td>Sealing gas</td>
<td>No sealing</td>
</tr>
<tr>
<td></td>
<td></td>
<td>Water penetration</td>
</tr>
<tr>
<td></td>
<td></td>
<td>Peeling</td>
</tr>
<tr>
<td></td>
<td></td>
<td>Surface contamination</td>
</tr>
<tr>
<td></td>
<td></td>
<td>Insufficient airtightness</td>
</tr>
<tr>
<td></td>
<td></td>
<td>Impure sealing gas</td>
</tr>
<tr>
<td></td>
<td></td>
<td>Particles</td>
</tr>
<tr>
<td></td>
<td></td>
<td>Open circuit</td>
</tr>
<tr>
<td></td>
<td></td>
<td>Short circuit</td>
</tr>
<tr>
<td></td>
<td></td>
<td>Increased leakage current</td>
</tr>
<tr>
<td>Input/output</td>
<td>Static electricity</td>
<td>Diffusion junction</td>
</tr>
<tr>
<td>pin</td>
<td>Surge</td>
<td>breakdown</td>
</tr>
<tr>
<td></td>
<td>Over voltage</td>
<td>Oxide film damage</td>
</tr>
<tr>
<td></td>
<td>Over current</td>
<td>Metallization</td>
</tr>
<tr>
<td></td>
<td></td>
<td>defect/destruction</td>
</tr>
<tr>
<td></td>
<td></td>
<td>Open circuit</td>
</tr>
<tr>
<td></td>
<td></td>
<td>Short circuit</td>
</tr>
<tr>
<td></td>
<td></td>
<td>Increased leakage current</td>
</tr>
<tr>
<td>Others</td>
<td>Alpha particles</td>
<td>Electron-hole pair generation</td>
</tr>
<tr>
<td></td>
<td>High electric field</td>
<td>Surface inversion</td>
</tr>
<tr>
<td></td>
<td>Noise</td>
<td>Soft error</td>
</tr>
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<td>Increased leakage current</td>
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</table>